

25/10/24.

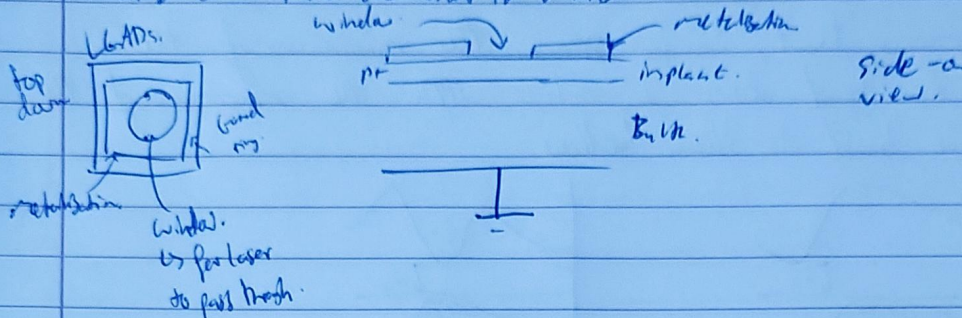
## MALTA Meeting.

$$I(x) = -q \cdot v \cdot E_0$$

↓ *find numerically? might not be possible analytically*

- ST Bonn → Weighing field calculation tool.

Electrons is what we are about in MALTA.



- Jonathan's Resis Section on this → variation in the bond gaps.
- "Indirect Semiconductor".
- Standard library / website for interacting with the stages.
- Bika gitlab for test code → Jonathan.

- Jonathan on Vey PSI. → jonathan.mulvey@psi.ch.  
↳ Ask for password for windows.

- Thursday 12:30 in lab. → test interlocks. → *not plug laser into lens. → cap laser, check.*
- Get laser & beam monitor on scope.  
↳ See if the beam monitor system & trigger show the same. + slight delay.

- Oscilloscope acquisition software.

Bilpa meeting 11 Tuesdays. → 17th for MALTA.



Laser photon energy  $\rightarrow E = \frac{hc}{\lambda} = 1.17 \text{ eV}$   
 $1064 \text{ nm.}$

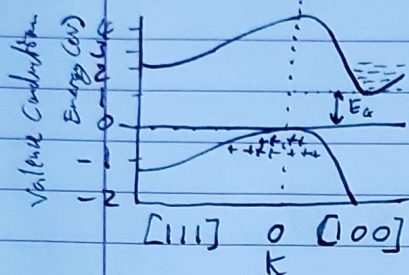
~~Energy required to produce e-h pair in Silicon~~ Energy required to produce e-h pair in Silicon  $\approx 3.6 \text{ eV.}$

So how does laser produce eh pairs in Silicon?

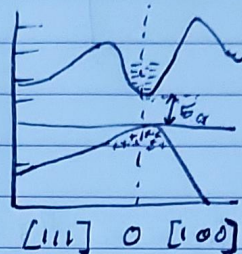
Indirect Semiconductors.

Silicon is an indirect semiconductor.

This means, that, in  $k$  space, the minimum of the conduction band does not align with the maximum of the valence band. As shown below.



Indirect Semiconductors  
 e.g. Si, Ge



Direct Semiconductors.  
 e.g. GaAs

~~$E_g$  in Silicon is  $\sim 1.12 \text{ eV}$~~ , but since the minima & maxima don't match up in  $k$  space, ~~the~~ there is extra energy required to alter the momentum ~~of~~ of the electron/hole. (as  $p = \hbar k$ ).  $\therefore$  average energy ~~the~~ required for eh pair  $\sim 3.6 \text{ eV.}$

However, ~~it~~ it is possible for this momentum change to come from phonons in the crystal lattice, & therefore it is possible for the transition to occur for  $E_{ph} < 3.6 \text{ eV}$  &  $E_{ph} > 1.12 \text{ eV}$ . Phonon energy is dependent on the Bose-Einstein distribution,  $\therefore$  the probability of this indirect transition is temperature dependent.